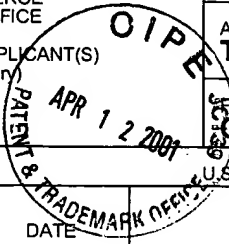


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			APPLICANT TETASUYA YANO ET AL.				
			FILING DATE October 29, 1999		GROUP 1652		
U.S. PATENT DOCUMENTS							
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EXAMINER <i>E. Slobodovskiy</i>				DATE CONSIDERED <i>07/1/01</i>			

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